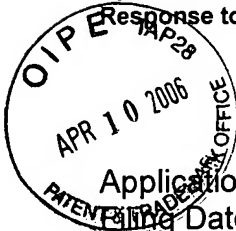


Response to November 10, 2005 Final OA

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

Application Serial No. .... 10/678,513  
 Filing Date ..... October 3, 2003  
 Inventor ..... Werner Juengling  
 Assignee ..... Micron Technology, Inc.  
 Group Art Unit ..... 2823  
 Examiner ..... Brook Kebede  
 Attorney's Docket No. .... MI22-2391  
 Customer No. .... 021567  
 Title: Semiconductor Processing Methods Of Forming A Contact Opening To A  
 Conductive Line and Methods of Forming Substrate Active Area Source/Drain  
 Regions

**RESPONSE TO NOVEMBER 10, 2005 FINAL OFFICE ACTION**  
**ACCOMPANYING REQUEST FOR CONTINUED EXAMINATION (RCE)**

To: Mail Stop: RCE  
 Commissioner for Patents  
 P.O. Box 1450  
 Alexandria, VA 22313-1450

From: D. Brent Kenady  
 Tel. 509-624-4276; Fax 509-838-3424  
 Wells St. John P.S.  
 601 W. First Avenue, Suite 1300  
 Spokane, WA 99201-3817

Responsive to the Final Office Action dated November 10, 2005, Applicant amends  
 and remarks as follows:

**AMENDMENTS**

Underlines indicate insertions and ~~strikeouts~~ indicate deletions.

**EV850818545**